



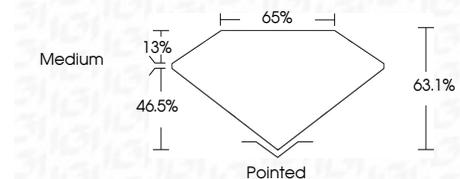
ELECTRONIC COPY

LG734516470
Report verification at igi.org



September 13, 2025
IGI Report Number **LG734516470**
Description **LABORATORY GROWN DIAMOND**
Shape and Cutting Style **SQUARE EMERALD CUT**
Measurements **8.26 X 8.11 X 5.12 MM**

GRADING RESULTS
Carat Weight **3.10 CARATS**
Color Grade **E**
Clarity Grade **VS 1**



ADDITIONAL GRADING INFORMATION
Polish **EXCELLENT**
Symmetry **EXCELLENT**
Fluorescence **NONE**
Inscription(s) **IGI LG734516470**
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



September 13, 2025
IGI Report No LG734516470
SQUARE EMERALD CUT
8.26 X 8.11 X 5.12 MM
3.10 CARATS
E
VS 1
63.1%
46.5%
Medium
Pointed
EXCELLENT
EXCELLENT
NONE
IGI LG734516470
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

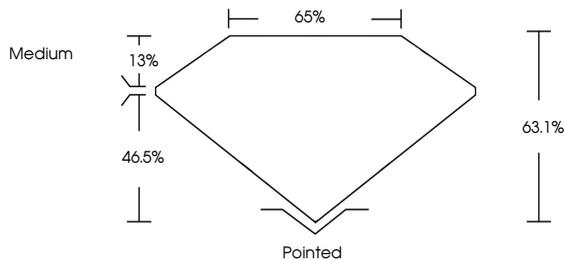
September 13, 2025
IGI Report Number **LG734516470**
Description **LABORATORY GROWN DIAMOND**
Shape and Cutting Style **SQUARE EMERALD CUT**
Measurements **8.26 X 8.11 X 5.12 MM**

GRADING RESULTS
Carat Weight **3.10 CARATS**
Color Grade **E**
Clarity Grade **VS 1**

ADDITIONAL GRADING INFORMATION
Polish **EXCELLENT**
Symmetry **EXCELLENT**
Fluorescence **NONE**
Inscription(s) **IGI LG734516470**

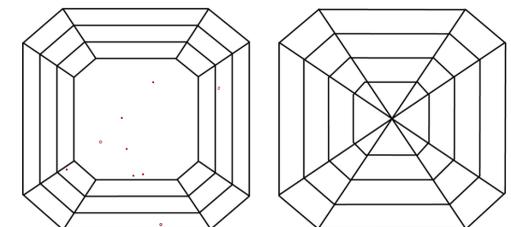
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

PROPORTIONS



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS
Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D	E	F	G	H	I	J	Faint	Very Light	Light
---	---	---	---	---	---	---	-------	------------	-------

CLARITY

IF	VS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.